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(21) International Application Number: PCT/EP99/02536 (22) International Filing Date: 15 April 1999 (15.04.99) (30) Priority Data: 947/98 27 April 1998 (27.04.98) CH (71) Applicant (for all designated States except US): CIBA SPECIALTY CHEMICALS HOLDING INC. [CH/CH]; Klybeckstrasse 141, CH-4057 Basel (CH). (72) Inventors; and (75) Inventors/Applicants (for US only): BAUER, Michael [DE/DE]; Burgblick 3, D-79299 Wittnau (DE). KAUFMANN, Werner [CH/CH]; Waldhofstrasse 64, CH-4310 Rheinfelden (CH). RYTZ, Gerhard [CH/CH]; 14, rue du Bassin, CH-2000 Neuenburg (CH). (74) Common Representative: CIBA SPECIALTY CHEMICALS HOLDING INC.; Patentabteilung, Klybeckstrasse 141, CH-4057 Basel (CH).		(81) Designated States: AE, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, CA, CH, CN, CU, CZ, DE, DK, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MD, MG, MK, MN, MW, MX, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, UA, UG, US, UZ, VN, YU, ZA, ZW, ARIPO patent (GH, GM, KE, LS, MW, SD, SL, SZ, UG, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GW, ML, MR, NE, SN, TD, TG). Published <i>With international search report.</i> <i>Before the expiration of the time limit for amending the claims and to be republished in the event of the receipt of amendments.</i>
(54) Title: PROCESS FOR THE PREPARATION OF UV PROTECTIVE COATINGS BY PLASMA-ENHANCED DEPOSITION		
(57) Abstract This invention relates to a process for the preparation of UV protective coatings by plasma-enhanced vacuum deposition, using hydroxyphenyl-s-triazines as UV absorbers. This invention also relates to the use of hydroxyphenyl-s-triazines in plasma-enhanced vacuum depositions and to the substrates coated by this process.		